Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L2	27	(Ishibashi.in. or Anelva.as. or (Japan near2 Science).as.) and ((Pt or platinum) near3 (wire or mesh or filament or coil or ((heat$3 or hot) near2 element)))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/07 14:30
L3	4	(Ishibashi.in. or Anelva.as. or (Japan near2 Science).as.) and ((Pt or platinum) near3 (filament or coil or ((heat$3 or hot) near2 element)))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/07 14:32
L4	23	L2 not L3	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/07 14:32
L5	20	(Ishibashi.in. or Anelva.as. or (Japan near2 Science).as.) and ((Pt or platinum) with (clean$3 or etch$3))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/07 14:33
L6	8	(Ishibashi.in. or Anelva.as. or (Japan near2 Science).as.) and ((Pt or platinum) with (filament or coil or ((heat$3 or hot) near2 element)))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/07 14:34
L7	11	(Ishibashi.in. or Anelva.as. or (Japan near2 Science).as.) and ((((clean$3 or etch$3 or fluorine or chlorine or fluorin$5 or chlorin$5 or halogen$5 or halide) near2 gas) with (filament or coil or ((heat$3 or hot) near2 element)))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/07 14:39
L8	7	(Ishibashi.in. or Anelva.as. or (Japan near2 Science).as.) and ((((clean$3 or etch$3 or fluorine or chlorine or fluorin$5 or chlorin$5 or halogen$5 or halide) near2 gas) same (temperature or heat$4 or hot or wire or filament or mesh or coil or element) same (Pt or platinum))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/07 14:41
L9	2583	(427/561,562,569,585,570,573).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/04/07 14:42
L10	864	(427/235,237).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/04/07 14:43

L11	2835	(427/248.1,255.23,255.28).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/04/07 14:43
L12	545	(427/444).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/04/07 14:43
L13	919	(118/722,70).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/04/07 14:43
L14	2295	(134/1.1,1.2,1.3,19).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/04/07 14:43
L15	520	(216/37,63).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/04/07 14:43
L16	73	(118/723HC).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/04/07 14:49
L17	5	L16 and (Pt or platinum)	US-PGPUB; USPAT	OR	ON	2005/04/07 14:50
L18	829	(134/22.1).CCLS.	US-PGPUB; USPAT	OR	OFF	2005/04/07 14:50
L19	35	L18 and (Pt or platinum)	US-PGPUB; USPAT	OR	ON	2005/04/07 14:54
L20	181	L18 and ((chamber or vessel or reactor) near2 wall)	US-PGPUB; USPAT	OR	ON	2005/04/07 15:06
L21	51	L15 and (Pt or platinum)	US-PGPUB; USPAT	OR	ON	2005/04/07 15:08
L22	129	L14 and (Pt or platinum)	US-PGPUB; USPAT	OR	ON	2005/04/07 15:08
L23	120	L22 not L19	US-PGPUB; USPAT	OR	ON	2005/04/07 15:12
L24	54	L10 and (Pt or platinum)	US-PGPUB; USPAT	OR	ON	2005/04/07 15:14
L25	9653	L9 or L10 or L11 L12 L13 L14 L15 L16 L18	US-PGPUB; USPAT	OR	ON	2005/04/07 15:15
L26	520	(216/37,63).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/04/07 15:15
L27	73	(118/723HC).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/04/07 15:15
L28	0	L27 and L26	US-PGPUB; USPAT	OR	ON	2005/04/07 15:15
L29	2295	(134/1.1,1.2,1.3,19).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/04/07 15:15

L30	48	L29 and (L26 or L27)	US-PGPUB; USPAT	OR	ON	2005/04/07 15:16
L31	152	L25 and ((Pt or platinum) with (hot or filament or coil or wire or mesh or heating or plate or foil or tube or rod))	US-PGPUB; USPAT	OR	ON	2005/04/07 15:17
L33	2583	(427/561,562,569,585,570,573). CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/04/07 15:27
L34	864	(427/235,237).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/04/07 15:27
L35	2835	(427/248.1,255.23,255.28).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/04/07 15:27
L36	545	(427/444).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/04/07 15:27
L37	919	(118/722,70).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/04/07 15:27
L38	8995	L33 L34 L35 L36 L37 L29 L26 L27	US-PGPUB; USPAT	OR	ON	2005/04/07 15:27
L39	79	L38 and ((Pt or platinum) with (clean$3 or etch$3))	US-PGPUB; USPAT	OR	ON	2005/04/07 15:27
L40	4274	((Pt or platinum) with (filament or coil or ((heat$3 or hot) near2 element)))	US-PGPUB; USPAT	OR	ON	2005/04/07 15:28
L41	113	L40 same (((clean$3 or etch$3 or fluorine or chlorine or fluorin$5 or chlorin$5 or halogen$5 or halide) near2 gas) or Cl2 or F2 or "Cl.sub. 2" or "F.sub.2" or $8fluoride or $8chloride or NF3 or "NF.sub.3" or CF4 or "CF.sub.4" or C2F6 or "C. sub.2F.sub.6" or "C.sub.2 F.sub.6" or C3F8 or "C.sub.3 F.sub.8" or "C.sub.3F.sub.8" or CCl4 or "CCl. sub.4" or C2ClF5 or ClF3 or "ClF. sub.3" or CClF3 or "CClF.sub.3" or SF6 or "SF.sub.6")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/07 15:30

L42	113	L40 same (((clean$3 or etch$3 or fluorine or chlorine or fluorin$5 or chlorin$5 or halogen$5 or halide) near2 gas) or Cl2 or F2 or "Cl.sub.2" or "F.sub.2" or $8fluoride or $8chloride or NF3 or "NF.sub.3" or CF4 or "CF.sub.4" or C2F6 or "C.sub.2F.sub.6" or "C.sub.2 F.sub.6" or C3F8 or "C.sub.3 F.sub.8" or "C.sub.3F.sub.8" or CCl4 or "CCl.sub.4" or C2ClF5 or ClF3 or "ClF.sub.3" or CClF3 or "CClF.sub.3" or SF6 or "SF.sub.6")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/07 15:30
L43	4274	((Pt or platinum) with (filament or coil or ((heat$3 or hot) near2 element)))	US-PGPUB; USPAT	OR	ON	2005/04/07 15:32
L44	27	L43 same (clean$3 or etch$3) same (fluorine or chlorine or fluorin$5 or chlorin$5 or halogen$5 or halide or Cl2 or F2 or "Cl.sub.2" or "F.sub.2" or $8fluoride or $8chloride or NF3 or "NF.sub.3" or CF4 or "CF.sub.4" or C2F6 or "C.sub.2F.sub.6" or "C.sub.2 F.sub.6" or C3F8 or "C.sub.3 F.sub.8" or "C.sub.3F.sub.8" or CCl4 or "CCl.sub.4" or C2ClF5 or ClF3 or "ClF.sub.3" or CClF3 or "CClF.sub.3" or SF6 or "SF.sub.6")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/07 15:32
L45	753	((clean$4 or etch$4 or ((remov$5 or eliminat$5) near2 (coat$4 or film or layer or contamin$9))) with (surface or inner or interior or inside or wall) with (reactor or chamber or vessel or vessell)) and ((clean$4 or etch$4 or gas$5 or vapor$4) same (fluorine or chlorine or fluorin$5 or chlorin$5 or halogen$5 or halide or Cl2 or F2 or "Cl.sub.2" or "F.sub.2" or $8fluoride or $8chloride or NF3 or "NF.sub.3" or CF4 or "CF.sub.4" or C2F6 or "C.sub.2F.sub.6" or "C.sub.2 F.sub.6" or C3F8 or "C.sub.3 F.sub.8" or "C.sub.3F.sub.8" or CCl4 or "CCl.sub.4" or C2ClF5 or ClF3 or "ClF.sub.3" or CClF3 or "CClF.sub.3" or SF6 or "SF.sub.6")) and ((hot or heat$4) near3 (coil or filament or wire or mesh or Pt or platinum))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/07 15:52

L46	104	L45 and L25	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/07 15:44
L47	9	((clean$4 or etch$4 or ((remov$5 or eliminat$5) near2 (coat$4 or film or layer or contamin$9))) with (surface or inner or interior or inside or wall) with (reactor or chamber or vessel or vessell)) and ((clean$4 or etch$4 or gas$5 or vapor$4) same (fluorine or chlorine or fluorin$5 or chlorin$5 or halogen$5 or halide or Cl2 or F2 or "Cl.sub.2" or "F.sub.2" or $8fluoride or $8chloride or NF3 or "NF.sub.3" or CF4 or "CF.sub.4" or C2F6 or "C.sub.2F.sub.6" or "C.sub.2 F.sub.6" or C3F8 or "C.sub.3 F.sub.8" or "C.sub.3F.sub.8" or CCl4 or "CCl.sub.4" or C2ClF5 or ClF3 or "ClF.sub.3" or CClF3 or "CClF.sub.3" or SF6 or "SF.sub. 6")) and ((hot or heat$4) near3 (coil or filament or wire or mesh or Pt or platinum))	EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/07 15:43
L48	1	"5647945".pn.	US-PGPUB; USPAT	OR	ON	2005/04/07 15:44
L49	0	L48 and (Pt or platinum)	US-PGPUB; USPAT	OR	ON	2005/04/07 15:44

| L50 | 10 | ((clean$4 or etch$4 or ((remov$5 or eliminat$5) near2 (coat$4 or film or layer or contamin$9))) with (surface or inner or interior or inside or wall) with (reactor or chamber or vessel or vessell)) and ((clean$4 or etch$4 or gas$5 or vapor$4) same (fluorine or chlorine or fluorin$5 or chlorin$5 or halogen$5 or halide or Cl2 or F2 or "Cl.sub.2" or "F.sub.2" or $8fluoride or $8chloride or NF3 or "NF.sub.3" or CF4 or "CF.sub.4" or C2F6 or "C.sub.2F.sub.6" or "C. sub.2 F.sub.6" or C3F8 or "C.sub.3 F.sub.8" or "C.sub.3F.sub.8" or CCl4 or "CCl.sub.4" or C2ClF5 or ClF3 or "ClF.sub.3" or CClF3 or "CClF.sub.3" or SF6 or "SF.sub. 6")) and ((hot or heat$4 or temperature) with (coil or filament or wire or mesh or Pt or platinum or element or plate or rod or foil or tube) with (activat$6 or decompos$5) with (gas$6 or vapor$4 or fluorine or chlorine or fluorin$5 or chlorin$5 or halogen$5 or halide or Cl2 or F2 or "Cl.sub.2" or "F.sub.2" or $8fluoride or $8chloride or NF3 or "NF.sub.3" or CF4 or "CF.sub.4" or C2F6 or "C.sub.2F.sub.6" or "C. sub.2 F.sub.6" or C3F8 or "C.sub.3 F.sub.8" or "C.sub.3F.sub.8" or CCl4 or "CCl.sub.4" or C2ClF5 or ClF3 or "ClF.sub.3" or CClF3 or "CClF.sub.3" or SF6 or "SF.sub. 6")) and ((Pt or platinum) with (heat$4 or hot or wire or mesh or filament or coil or element or plate or rod or tube or foil)) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/04/07 16:03 |

L51	127	((clean$4 or etch$4 or ((remov$5 or eliminat$5) near2 (coat$4 or film or layer or contamin$9))) with (surface or inner or interior or inside or wall) with (reactor or chamber or vessel or vessell)) and ((clean$4 or etch$4 or gas$5 or vapor$4) same (fluorine or chlorine or fluorin$5 or chlorin$5 or halogen$5 or halide or Cl2 or F2 or "Cl.sub.2" or "F.sub.2" or $8fluoride or $8chloride or NF3 or "NF.sub.3" or CF4 or "CF.sub.4" or C2F6 or "C.sub.2F.sub.6" or "C.sub.2 F.sub.6" or C3F8 or "C.sub.3 F.sub.8" or "C.sub.3F.sub.8" or CCl4 or "CCl.sub.4" or C2ClF5 or ClF3 or "ClF.sub.3" or CClF3 or "CClF.sub.3" or SF6 or "SF.sub.6")) and ((hot or heat$4 or temperature or activat$5 or decompos$5) with (coil or filament or wire or mesh or Pt or platinum or element or plate or rod or foil or tube) with (gas$6 or vapor$4 or fluorine or chlorine or fluorin$5 or chlorin$5 or halogen$5 or halide or Cl2 or F2 or "Cl.sub.2" or "F.sub.2" or $8fluoride or $8chloride or NF3 or "NF.sub.3" or CF4 or "CF.sub.4" or C2F6 or "C.sub.2F.sub.6" or "C.sub.2 F.sub.6" or C3F8 or "C.sub.3 F.sub.8" or "C.sub.3F.sub.8" or CCl4 or "CCl.sub.4" or C2ClF5 or ClF3 or "ClF.sub.3" or CClF3 or "CClF.sub.3" or SF6 or "SF.sub.6")) and ((Pt or platinum) with (heat$4 or hot or wire or mesh or filament or coil or element or plate or rod or tube or foil))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/07 16:13
L52	117	L51 not L50	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/07 16:07
L53	9	L52 and L25	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/07 16:08

L54	108	L52 not L53	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/07 16:08
L55	66	((clean$4 or etch$4 or ((remov$5 or eliminat$5) near2 (coat$4 or film or layer or contamin$9))) with (surface or inner or interior or inside or wall) with (reactor or chamber or vessel or vessell)) and ((clean$4 or etch$4 or gas$5 or vapor$4) same (fluorine or chlorine or fluorin$5 or chlorin$5 or halogen$5 or halide or Cl2 or F2 or "Cl.sub.2" or "F.sub.2" or $8fluoride or $8chloride or NF3 or "NF.sub.3" or CF4 or "CF.sub.4" or C2F6 or "C.sub.2F.sub.6" or "C.sub.2 F.sub.6" or C3F8 or "C.sub.3 F.sub.8" or "C.sub.3F.sub.8" or CCl4 or "CCl.sub.4" or C2ClF5 or ClF3 or "ClF.sub.3" or CClF3 or "CClF.sub.3" or SF6 or "SF.sub.6")) and ((hot or heat$4 or temperature or activat$5 or decompos$5) with (Pt or platinum) with (gas$6 or vapor$4 or fluorine or chlorine or fluorin$5 or chlorin$5 or halogen$5 or halide or Cl2 or F2 or "Cl.sub.2" or "F.sub.2" or $8fluoride or $8chloride or NF3 or "NF.sub.3" or CF4 or "CF.sub.4" or C2F6 or "C.sub.2F.sub.6" or "C.sub.2 F.sub.6" or C3F8 or "C.sub.3 F.sub.8" or "C.sub.3F.sub.8" or CCl4 or "CCl.sub.4" or C2ClF5 or ClF3 or "ClF.sub.3" or CClF3 or "CClF.sub.3" or SF6 or "SF.sub.6"))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/07 16:15
L56	5	L55 and L25	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/07 16:15
L57	61	L55 not L56	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/07 16:15